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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/560,745	05/30/2006	Naoki Oyanagi	Q76253	1691
23373 7590 03/13/2008 SUGHRUE MION, PLLC 2100 PENNSYLVANIA AVENUE, N.W.			EXAMINER	
			HITESHEW, FELISA CARLA	
SUITE 800 WASHINGTON, DC 20037		ART UNIT	PAPER NUMBER	
			1792	
			MAIL DATE	DELIVERY MODE
			03/13/2008	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Application No. Applicant(s) 10/560 745 OYANAGI NAOKI

000 4 // 0	10/300,743	OTANAGI, NAONI				
Office Action Summary	Examiner	Art Unit				
	Felisa C. Hiteshew	1792				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address						
Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPL. WHICHEVER IS LONGER, FROM THE MAILING DV. Extensions of time may be available under the provisions of 37 CFR 1.1 after 55% (6) MONTHS from the mailing date of the communication. If NO period for reply vis specified above, the maximum statutory period. Failure to reply within the soft or returned period for reply with USA. Any reply received by the Office later than three months after the mailing earned patent term degliament. See 37 CFR 1.7(Hp).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nety filed the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on						
	action is non-final.					
3) Since this application is in condition for allowar	nce except for formal matters, pro	secution as to the merits is				
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
4) Claim(s) 1-11 is/are pending in the application.						
4a) Of the above claim(s) <u>5-7</u> is/are withdrawn from consideration.						
5)⊠ Claim(s) <u>8-11</u> is/are allowed.						
6)⊠ Claim(s) <u>1-4</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or	r election requirement.					
Application Papers						
9)☐ The specification is objected to by the Examiner.						
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119						
i.						
12)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a)⊠ All b)□ Some * c)□ None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the priority documents have been received in this National Stage						
application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list of the certified copies not received.						
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da	ite				
3) Information Disclosure Statement(s) (PTO/SE/08) Paper No(s)/Mail Date 05/30/2006 & 12/15/2005.	5) Notice of Informal F	atent Application				

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DETAILED ACTION

Priority

Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which
papers have been placed of record in the file.

Information Disclosure Statement

The PTOL 1449s of 12/15/2005 and 05/30/2006 have been received, reviewed and considered.

Claim Rejections - 35 USC § 103

- The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- Claims 1-3 are rejected under 35 U.S.C. 103(a) as being unpatentable over Japanese Patent Abstract 04-016597 and Japanese Patent Abstract 2002-284599.

JP '597 teaches a sublimation re-crystallization method of producing SiC single crystals comprising a substrate (off-angle substrate) as a seed crystal made of a hexagonal SiC single crystal and having a principal growth surface whose orientation has been inclined from [0001] direction.

The difference being that JP '597 does not teach a SiC single crystal being cut, polished, washed, subjected to sacrificial oxidation, and surface-treated by HF washing.

JP'599 teaches a sublimation method for growing a SiC single crystal comprising an inert atmosphere under the condition that pressure is in the range of 100 - 300 Torr. Application/Control Number: 10/560,745

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a raw material heated to 2,200-2,300 *C, which is 30 to 100*C lower than the raw material with a growing speed adjusted to < 70 um/h. In the absence of unobvious results, it would have been obvious to one of ordinary skill in the art to determine through routine experimentation the optimum, operable process parameters limitations (i.e. crystal growth rate) in order to ensure proper orientation.

A reference is good not only for what it teaches by direct anticipation but also for what one of ordinary skill might reasonably infer from the teachings. In re Opprect 12 USPQ 2d 1235, 1236 (CAFC 1989); In re Bode 193 USPQ 12; In re Lamberti 192 USPQ 278; In re Bozek 163 USPQ 545, 549 (CCPA 1969); In re Van Mater 144 USPQ 421; In re Jacoby 135 USPQ 317; In re LeGrice 133 USPQ 365; In re Preda 159 USPQ 342 (CCPA 1968).

Allowable Subject Matter

- As allowable subject matter has been indicated, applicant's reply must either comply with all formal requirements or specifically traverse each requirement not complied with. See 37 CFR 1.111(b) and MPEP § 707.07(a).
- 5. Claims 4 and 8-11 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Felisa Hiteshew whose telephone number is (571) 272-1463. The examiner can normally be reached on Mondays through Thursday from 5:30 AM to 4:00 PM with Fridays off.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Barr, can be reached on (571) 272-1414. The fax phone number for the organization where this application or proceeding is assigned is (571) 273-1463.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system. see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866- 217-9197 (toll-free).

/Felisa C. Hiteshew/ Primary Examiner, Art Unit 1792